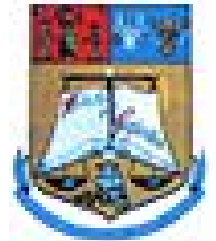




**NATIONAL INSTITUTE for LASER,  
PLASMA and RADIATION PHYSICS**  
Laser Department



9th National Seminar of Nanoscience and Nanotechnology,  
Romanian Academy, 16.03.2010

## **RECENT CONTRIBUTIONS IN NONLINEAR NANOPHOTONICS**

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# **“NONLINEAR AND INFORMATION PHOTONICS” GROUP**

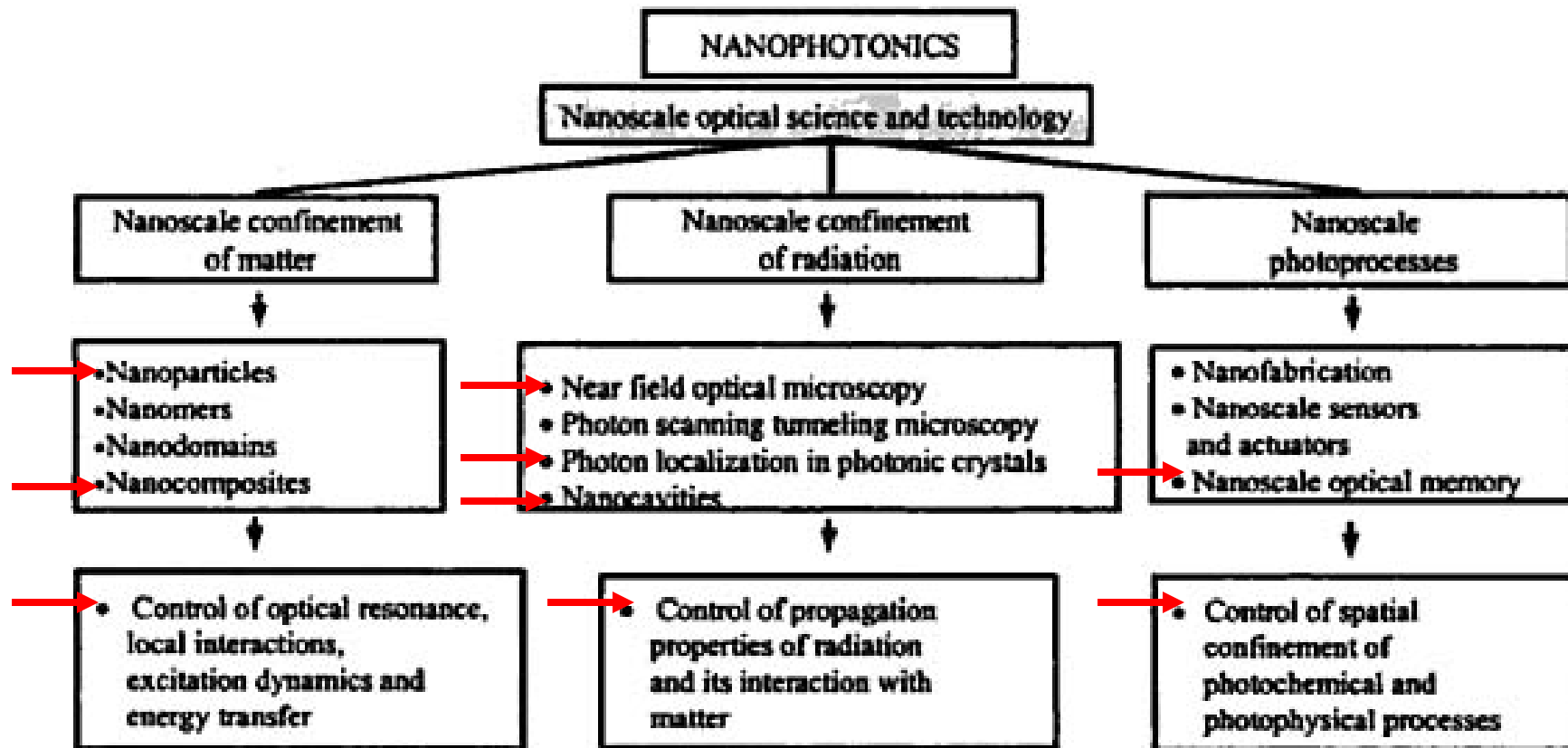
- **Prof. Dr. Valentin I. VLAD, M. Ro. Acad.**
- **Dr. Adrian PETRIS**
- **Dr. Mircea UDREA**
- **Dr. Mihaela STOICA**
- **Tatiana BAZARU - PhD student (B.U.- Physics)**
- **Petronela GHEORGHE - PhD student (B.U.- Physics)**
- **Ioan DANCUS - PhD student (B.U.- Physics)**
- **Silviu POPESCU – M.S. student (U.P.B.- Electronics)**
  
- **Dr. Valentin BARNA - part-time (B.U.)**
- **Dr. Vasile BABIN - part-time (NIOE)**
  
- **Tehn. Mariana BUZATU**

# OUTLINE

1. **Electronic and thermal nonlinear refractive indices of periodically nano-patterned and un-patterned silicon-on-insulator (SOI)**
2. **Theoretical and experimental dependence of effective optical linear and nonlinear refractive indices of nano-porous silicon (np-Si) on Si volume fill fraction, at different light wavelengths in visible and near-infrared**
3. **Experimental observation of huge, saturable and controlled nonlinear optical properties of CdTe quantum dots, in the case of strong quantum confinement (size  $\sim 2\text{nm}$ ) and near resonant interaction with the excitation light**
4. **Fast spatial soliton creation in lithium niobate crystals with a low power c.w. laser blue-violet diode, near the absorption edge of the crystals. Parallel propagation of femtosecond impulse in IR in arrays of soliton waveguides**
5. **Experimental observation of highly efficient forward- and backward-random laser effect (without optical cavity) in dye infiltrated nematic liquid crystals.**

# Introduction. Definition and main fields.

## Our research in nanophotonics

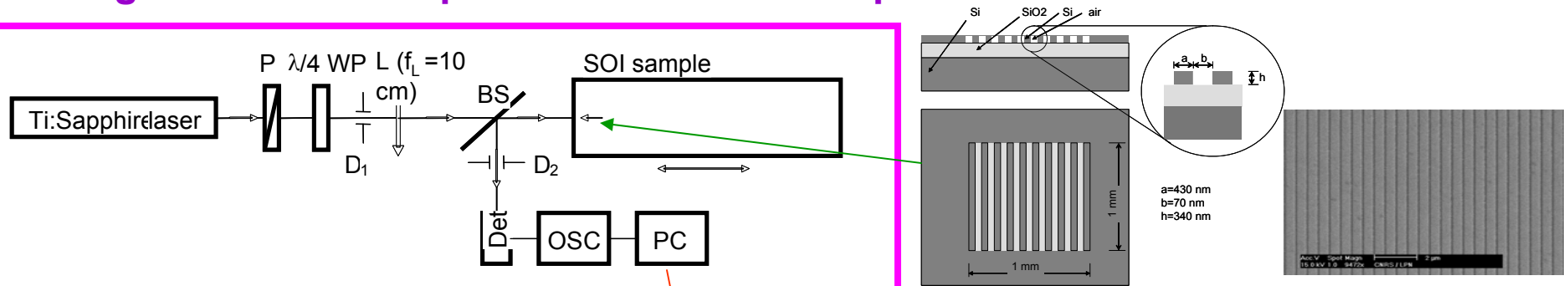


(Using the graph from P. Prasad, Nanophotonics, Wiley, 2004)

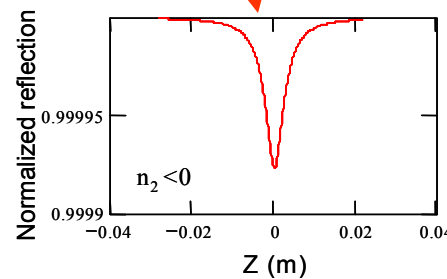
→ Research in NILPRP-NIP

# 1.1. Strong enhancement of the fast nonlinear response of periodically nano-structured SOI measured by double RZ-scan with a femto-laser

**Aim: High and ultra-fast photonic nonlinear response in SOI**



**Laser Ti:Sapphire** :  $\lambda=800\text{nm}$   
 $P_{\text{av}}=265\text{mW}$ , **75 fs**, **76 MHz**



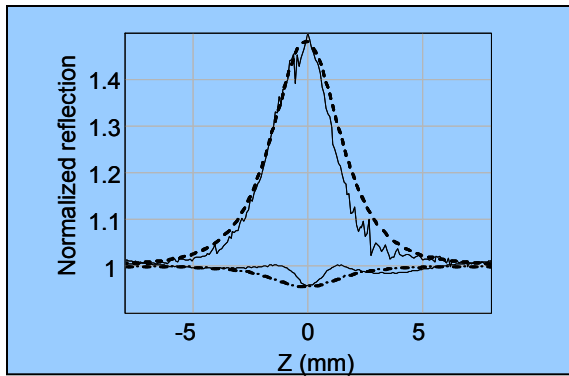
- SOI: Si ( $250\mu\text{m}$ )-SiO<sub>2</sub>( $2\mu\text{m}$ )-Si ( $340\text{ nm}$ )
- Periodic nano-structure:  $430\text{nm Si-}70\text{nm air}$  (e-beam litho.+RIE)
- $\lambda=800\text{ nm}$ :  $n_{\text{Si}}=3.7$ ;  $n_{\text{SiO}_2}=1.5$ ;  $\alpha_{\text{Si}}\sim 1000\text{ cm}^{-1}$

Normaliz. reflected power is:  $P(z) \propto \Delta n = n_2 I$ . Our formalism for RZ-scan leads to:

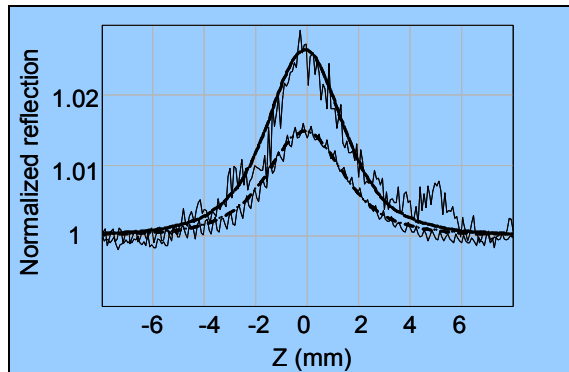
$$P(z) = 1 + \frac{2n_2 I_0}{n_0^2 - 1} \cdot \frac{1}{1 + (z/z_0)^2} = 1 + \frac{2\Delta n}{n_0^2 - 1} \cdot \frac{1}{1 + (z/z_0)^2} \quad (1)$$

**Collab. NILPRP with Univ. “La Sapienza” di Roma and Ecole Normale Superieure Paris, in the frame of EU Network of Excellence in Nanophotonics “PHOREMOST”**

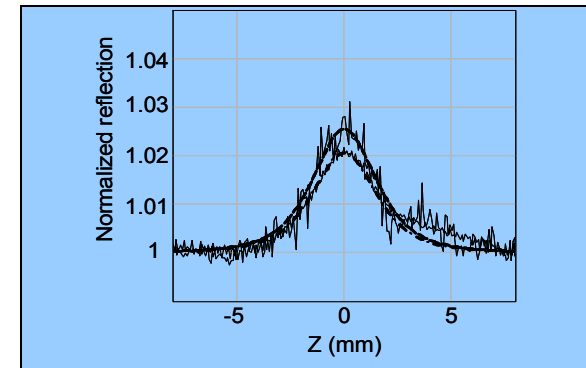
## 1.2. Double Z-scan (our method – separation of electronic and thermal NL)



SOI periodically nano-struct.



SOI



Si

c.w. Regime (sup. cont. graph):  $\Delta n_{th} = n_{2,th} I_0$

Mode-locking Regime (inf. cont. graph):  $\Delta n = \Delta n_{el} + \Delta n_{th} = n_{2,el} I_p + n_{2,th} I_{av} \rightarrow \Delta n_{el} = n_{2,el} I_p$

Best fit with (1) (dots, dash-dots)

### Electronic and thermal eff. nonlinear coefficients of nano-structured SOI, SOI and c-Si

$n_2(\text{m}^2/\text{W})$	SOI nano-struct.	SOI	Si
$n_{2,th} \times 10^{10}$	36	7.5	7.5
$n_{2,el} \times 10^{15}$	- 21.2	- 1.8	- 1.0

Fs Electronic Nonlinear Response (NR) of nano-structured SOI > 20 x NR of cSi wafer.

=> Fast nonlinear photonic devices with parameters controlled by simple nano-structures

Ref:1. A. Petris, V. I. Vlad et al., Electronic and thermal nonlinear refractive indices of SOI and nano-patterned SOI measured by Z-scan method, **Proc. SPIE**, **6785**, 67851F (2007)

2. A. Petris, V. I. Vlad et al, Femtosecond fifth order nonlinearities in SOI, **Proc. EOS Conf. "Optical Microsystems"**, Capri, 2009

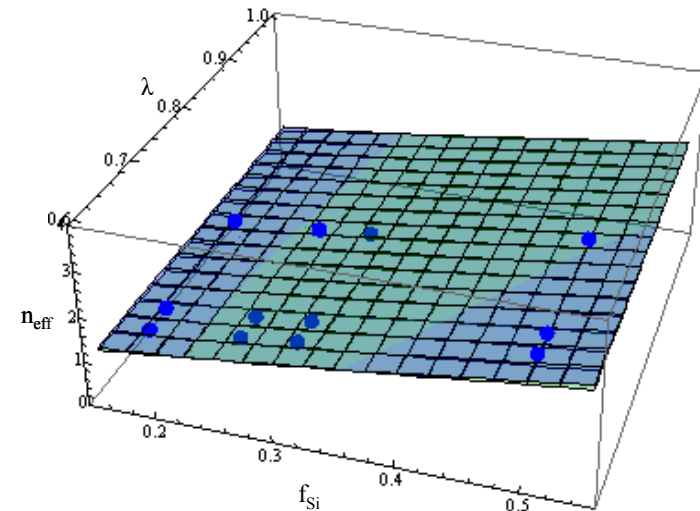
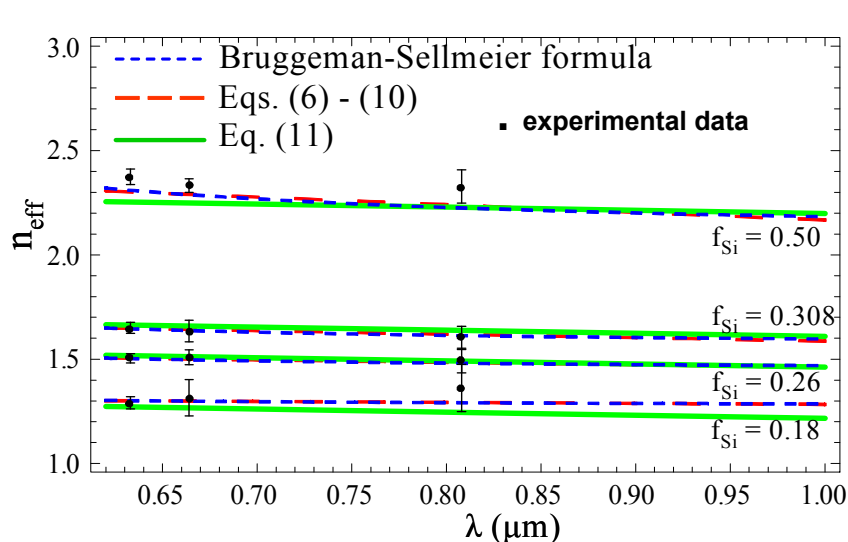
## 2.1. Effective linear refractive index of nano-porous silicon and its dependences on porosity and light wavelength

**Aim: Control of optical nonlinearity by nanostructuring (at diff. laser wavelengths)**

Bruggeman formalism:  $n_{eff} = \sqrt{\epsilon_{eff}} = \sqrt{\frac{1}{4} \left[ 2 - 3f_{Si} + \epsilon_{Si}(3f_{Si} - 1) + \sqrt{8\epsilon_{Si} + 2 - 3f_{Si} + \epsilon_{Si}(3f_{Si} - 1)} \right]}$

Sellmeier formula:  $n_{Si}^2 = 1 + \frac{A_1 \lambda^2}{\lambda^2 - B_1^2} + \frac{A_2 \lambda^2}{\lambda^2 - B_2^2} + \frac{A_3 \lambda^2}{\lambda^2 - B_3^2}$  ( $A_i, B_j = const, at T = 300K$ )

Our approx. formula:  $n_{eff} \approx 3.07 \cdot f_{Si} - 0.148 \cdot \lambda + 0.812$  (11)



**Collab. NILPRP with IMT and NIMP; COST MP0702 "Towards Functional Sub-Wavelength Photonic Structures"- MC-member and WG 3 co-leader**

## 2.2. Effective nonlinear refractive index of nano-porous silicon and its dependences on porosity and light wavelength

Boyd-Bruggeman formula:

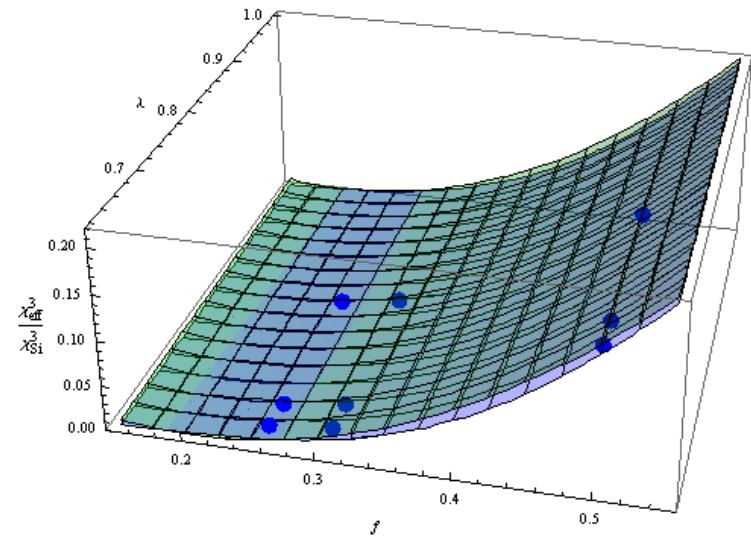
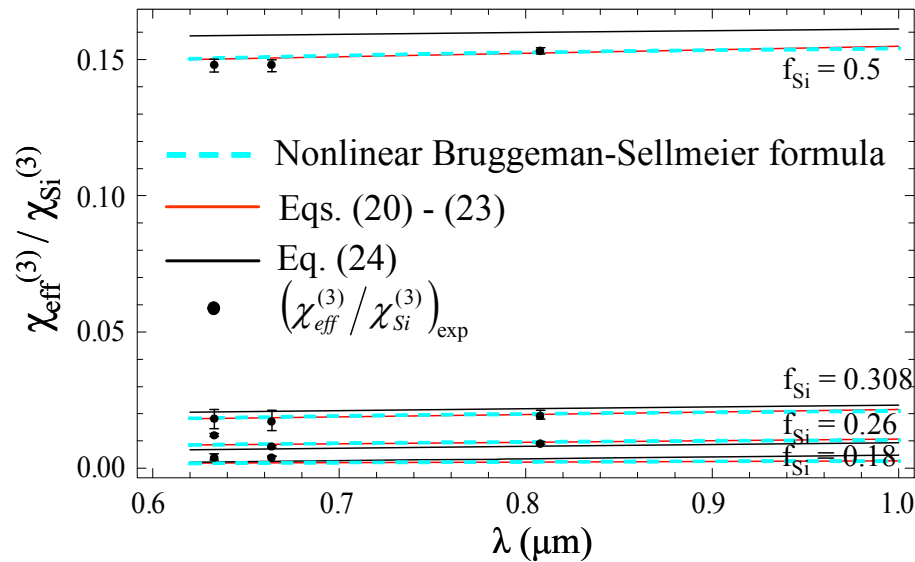
$$\frac{\chi_{eff}^{(3)}}{\chi_{Si}^{(3)}} = \frac{1}{f_{Si}} \left( \frac{\partial \varepsilon_{eff}}{\partial \varepsilon_{Si}} \right)^2 = \frac{1}{f_{Si}} \left[ \frac{1}{4} \left( 3f_{Si} - 1 + \frac{2 - 9f_{Si}(f_{Si} - 1) + \varepsilon_{Si}(1 - 3f_{Si})^2}{\sqrt{8\varepsilon_{Si} + (2 - 3f_{Si} + \varepsilon_{Si}(3f_{Si} - 1))^2}} \right)^2 \right]$$

Sellmeier formula:

$$\varepsilon_{Si} = 1 + \frac{A_1 \lambda^2}{\lambda^2 - B_1^2} + \frac{A_2 \lambda^2}{\lambda^2 - B_2^2} + \frac{A_3 \lambda^2}{\lambda^2 - B_3^2}$$

Our approx. formula:

$$\frac{\chi_{eff}^{(3)}}{\chi_{Si}^{(3)}} \approx 1.8 \cdot f_{Si}^2 - 0.735 \cdot f_{Si} + 0.0068 \cdot \lambda + 0.072 \quad (24)$$





## 2.3. Effective nonlinear refractive index of nano-porous silicon and its dependences on porosity and light wavelength- Experiments

**Reflection I-scan** - our formalism leads to:

$$R(I) \approx 1 + \frac{0.04}{n_{eff}^2} \cdot \frac{\chi_{eff}^{(3)} \cdot I}{(n_{eff}^2 - 1)}$$

where:  $I$  is the laser beam intensity at distance  $z_R$  from the focus,  $z_R$  is the Rayleigh length of the beam (for  $w_0 = 4.827 \cdot 10^{-5}$  m and  $\lambda = 633$  nm, we get  $z_R = 1.2$  cm),  $w_0$  is the beam waist,

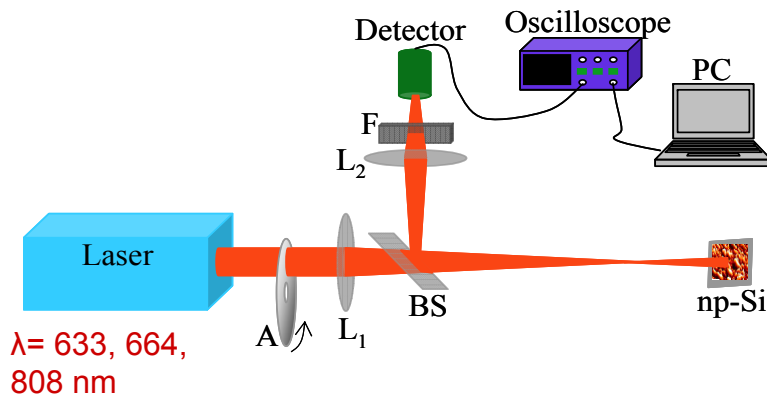
$$\chi_{eff}^{(3)} [esu] \approx 12.7 \cdot n_0^2 \cdot n_2 [cm^2 / W]$$

is the third-order nonlinear optical susceptibility of the sample and  $n_2$  is the nonlinear refractive index of the sample.

In the case of measurements on bulk Si sample,  $n_{eff} = n_{0Si}$  and

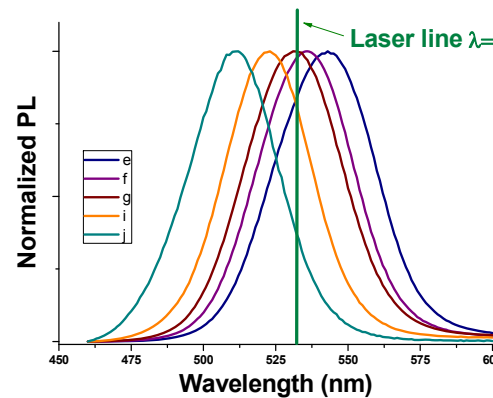
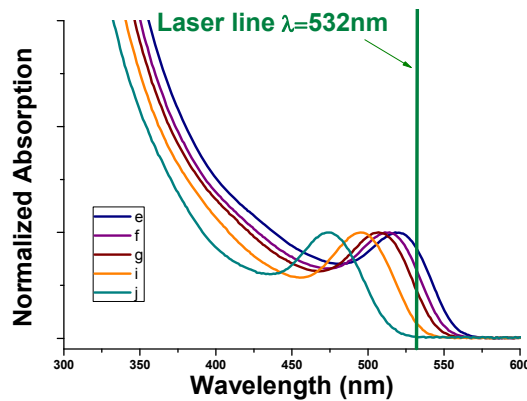
$$\frac{\chi_{eff}^{(3)}}{\chi_{Si}^{(3)}} \approx 4.785 \cdot 10^{-3} \cdot \frac{R_{np-Si} - 1}{R_{Si} - 1} \cdot (3.16 \cdot f_{Si} + 0.71)^2 \cdot [(3.16 \cdot f_{Si} + 0.71)^2 - 1] \quad \text{for } \lambda = 633\text{nm}$$

- Ref:** 1. T. Bazaru, V. I. Vlad, A. Petris, M. Miu, **J. Optoelectron. Adv. Mat.** **12** (1), 43-47 (2010)  
 2. T. Bazaru, V. I. Vlad, A. Petris, M. Miu, **Proc. SPIE, Micro- to Nano-Photonics, 2010**



# 3.1. Giant and controlled nonlinear optical properties of CdTe quantum dots in strong confinement regime – QD characterization

**Aim: Synthesis and measurement of giant tunable optical nonlinearity in QDs for switching and new photonic functionalities**



**All samples have the same QD concentration:**

$$\sim 2.65 \times 10^6 \text{ NC/l}$$

We used A. L. Rogach et al, J. Phys.Chem. C (2007) , for size calculation from the 1s-1s transition

Sample	1s-1s Abs. Peak (nm)	PL max (nm)	Size (nm)	$n_2$ ( $10^{-7} \text{cm}^2/\text{W}$ )	$I_{sat}$ ( $\text{W}/\text{cm}^2$ )
v108j	474	510.4	1.8	-1.36	-
v108i	495	522.4	2.0	-3.09	3409.9
v108g	507	531.3	2.1	-7.72	1424.4
v108f	511	535.4	2.2	-9.57	1111.7
v108e	518	542.1	2.2	-14.65	674.5

**Collab. NILPRP with Univ. Dresden, EU Network of Excellence in Nanophotonics “PHOREMOST” and COST MP0702**

## 3.2. Giant and controlled nonlinear optical properties of CdTe quantum dots in strong confinement regime –TZ scan experiments

**TZ-scan** –Sheik-Bahae & van Stryland formula:

$$T_{\beta=0}(z, \Delta\phi_0) \cong 1 + \frac{4\Delta\phi_0 Z}{(z^2 + 1)(z^2 + 9)}$$

where:

$x = z/z_0$  is the normalized distance;

$z_0$  – the Rayleigh distance;

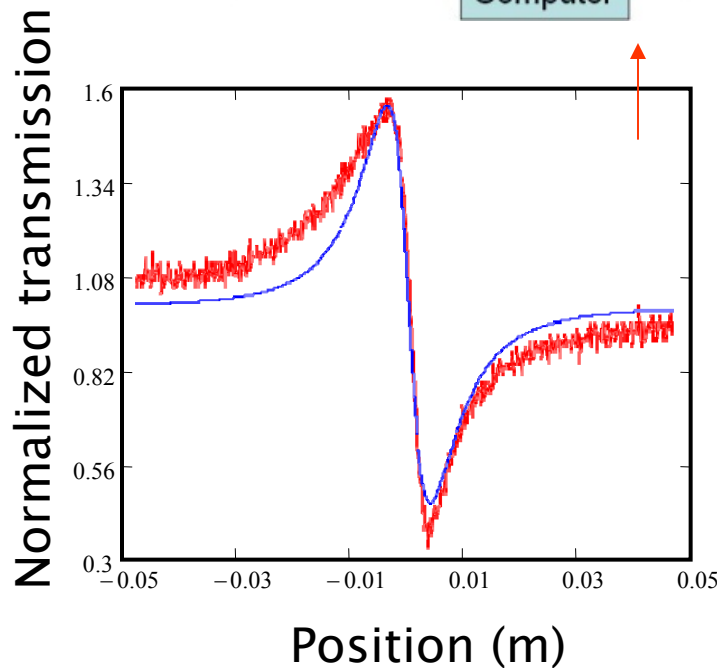
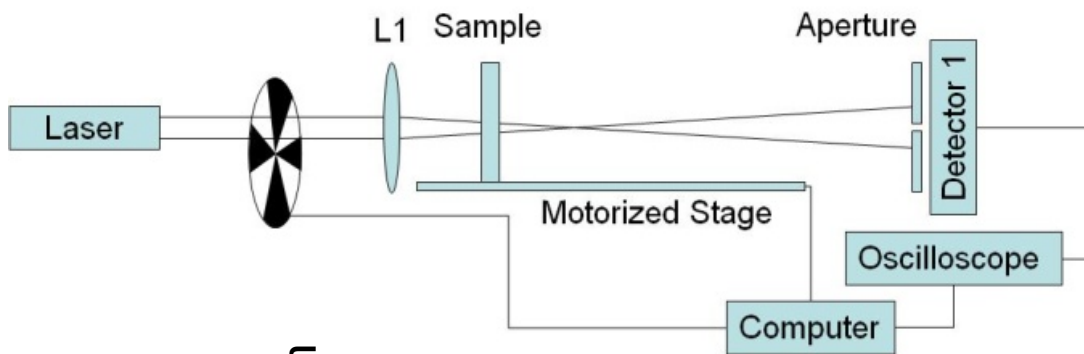
$$\Delta\phi_0 = k\Delta n_0 L_{eff};$$

$\Delta n_0$  – the **nonlinear induced refractive index change** in the focal plane;

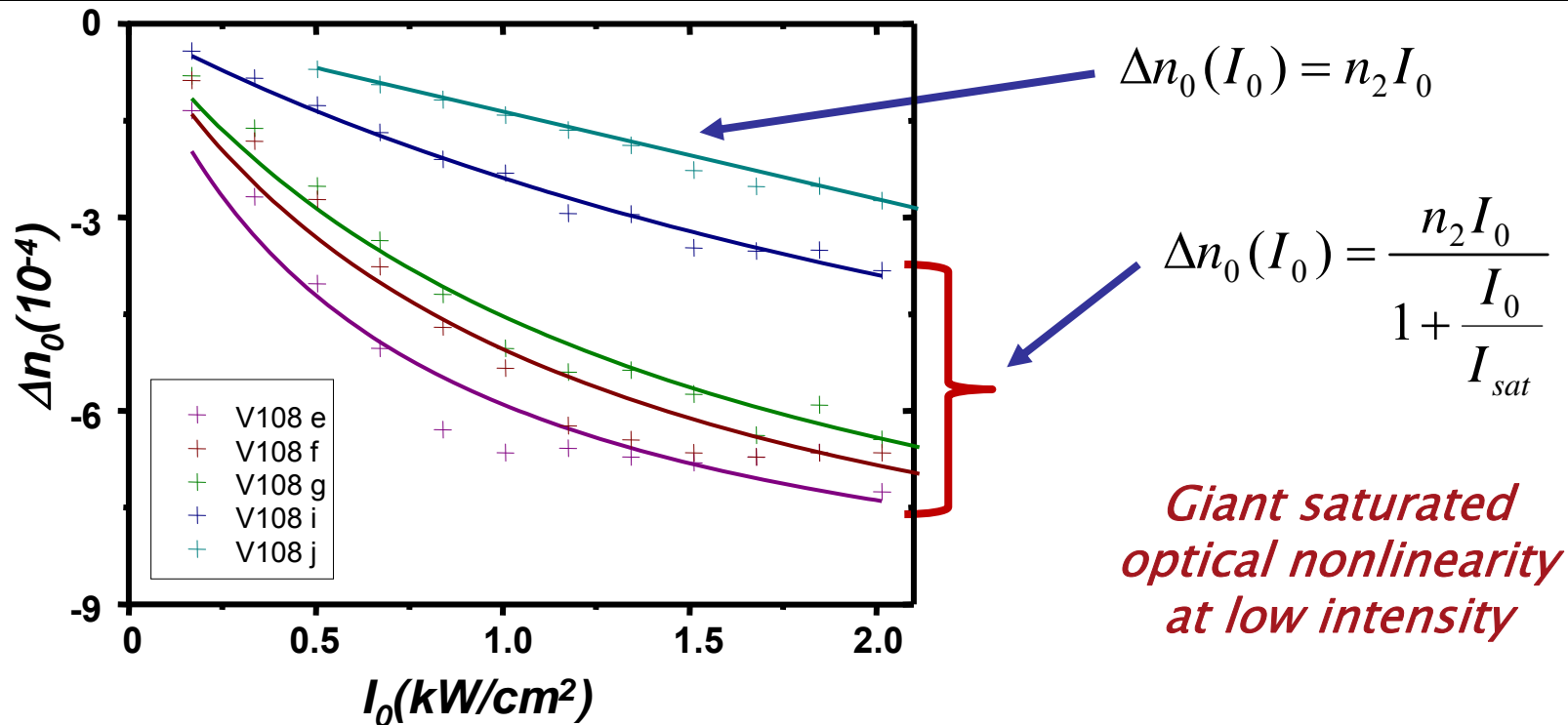
$L_{eff} = (1 - e^{-\alpha L})/\alpha$  – the effective length of the medium;

$\alpha$  – the linear absorption and

$L$  – the thickness of the medium.



### 3.3. Giant and controlled nonlinear optical properties of CdTe quantum dots in strong confinement regime – Saturated NL at low intensity



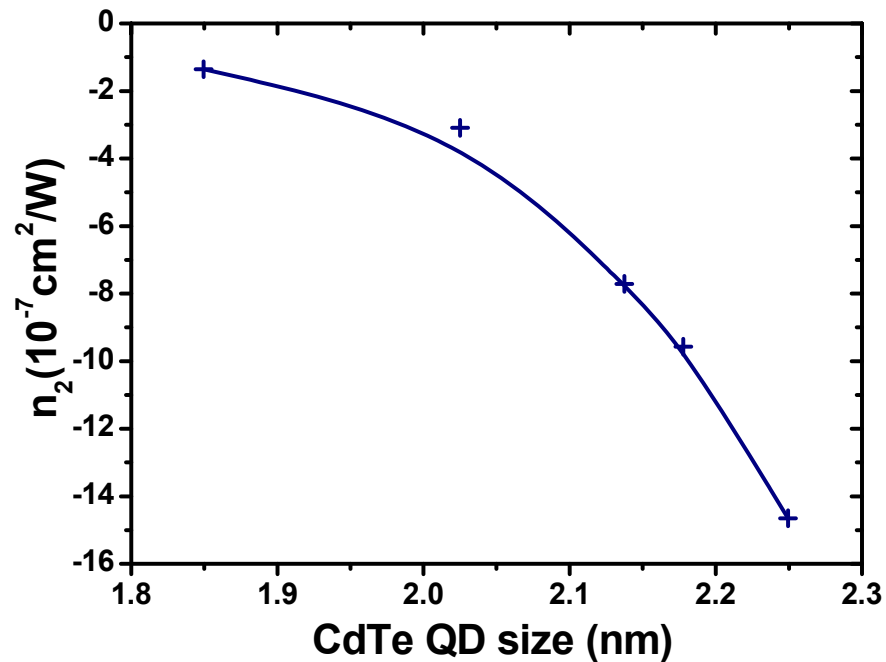
G.L. Tan et al. in Opt. Mat. (2004) obtained  $n_2 \sim -10^{-11} \text{ cm}^2/\text{W}$ ;

L. Pan et al. in Appl. Phys. Lett. (2007) obtained  $n_2 \sim -10^{-12} \text{ cm}^2/\text{W}$ ;

J. T. Seo et al. in Phys. Stat. Sol (c) (2004) obtained  $n_2 \sim -10^{-9} \text{ cm}^2/\text{W}$ ;

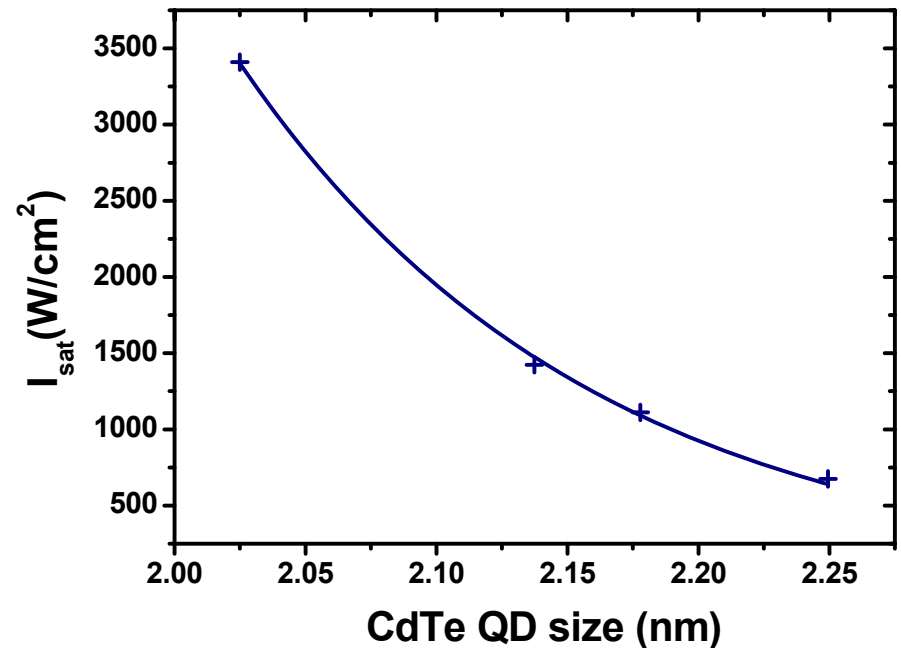
**I. Dancus, V.I. Vlad et al, Opt. Lett., March 2010:  $n_2 \sim -10^{-6} \text{ cm}^2/\text{W}$**

### 3.4. Giant and controlled nonlinear optical properties of CdTe quantum dots in strong confinement regime – Size dependent NL effects



Experimental nonlinear refractive index,  $n_2$ , shows an exponential decrease with the increase of the size,  $a$ , of the QDs

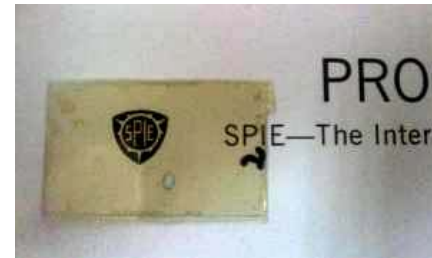
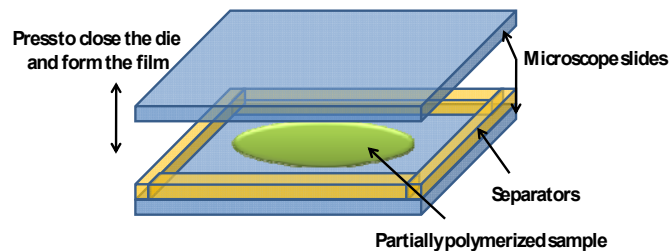
$$n_2(a) = 0.18 - 1.69 \cdot e^{-\frac{a}{0.16}}$$



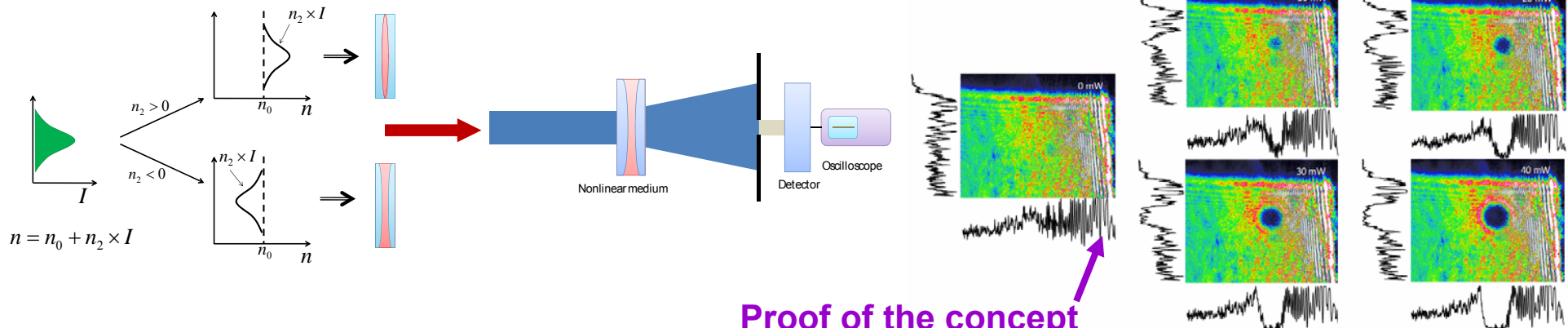
Experimental dependence of the saturation intensity shows an exponential decrease with the increase of the size of the CdTe QDs

$$I_{sat}(a) = 201.73 + 8.45 \cdot e^{-\frac{a}{0.12}}$$

## 3.5. Giant and controlled nonlinear optical properties of CdTe QDs in polystyrene – Eye exposure limiting to laser beams



**Concept of optical limiting device based on the induced nonlinear refractive index lens. The divergence of the lens is intensity dependent.**



**For laser beam diameter of 1mm, the threshold intensity for this optical limiting device is  $\sim 1\text{W}/\text{cm}^2$  and switching time  $\sim 1\mu\text{s}$**

- Ref:**
1. I. Dancus, V.I. Vlad et al, Sat. near-resonant refractive NL in CdTe QDs, **Optics Lett.**, 2010
  2. I. Dancus, V. I. Vlad et al, **J. Optoelectron. Adv. Mat.** 12 (1), 149-151 (2010)
  3. I. Dancus, V. I. Vlad et al, **Proc. SPIE, Micro- to Nano-Photonics**, 2010
  4. I. Dancus, V. I. Vlad et al, Size-dependent NL properties of Cd-Te QDs, **CLEO/Europe-EQEC Conf., Munich**, 2009

# 4.1. Fast spatial soliton and soliton waveguide creation in lithium niobate (LN) crystals with a low power c.w. laser blue-violet diode

First Bright Spatial Solitons in LN crystals: E. Fazio, A. Petris, V. I. Vlad et al, "Screening-photovoltaic bright solitons in LiNbO<sub>3</sub> and associated single-mode waveguides", Appl. Phys. Lett. 85, 2193 (2004)

Aim: Fast SWG creation with low power lasers at the absorption edge of LN-Fs propagation

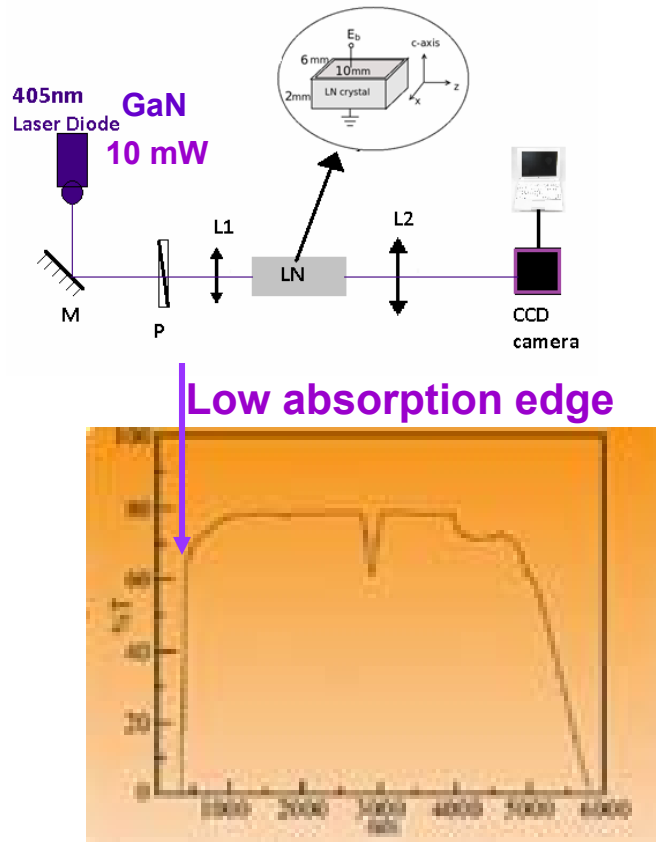


Fig.1. LN Transmission

([www.sp3plus.co.uk/lithium-niobate](http://www.sp3plus.co.uk/lithium-niobate))

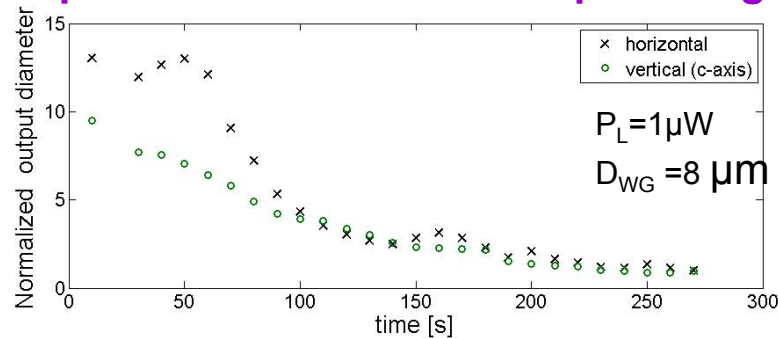


Fig.2. Time evolution of normalized output beam diameter at 405nm (single mode fiber after ~ 2 min; at 533nm,  $t_w \sim 30$  min)

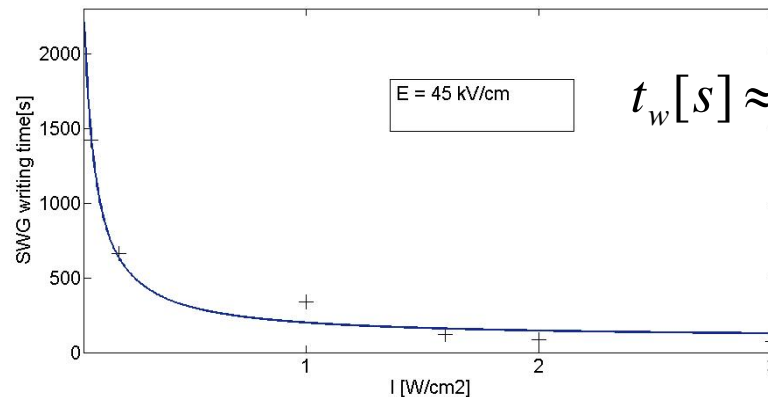
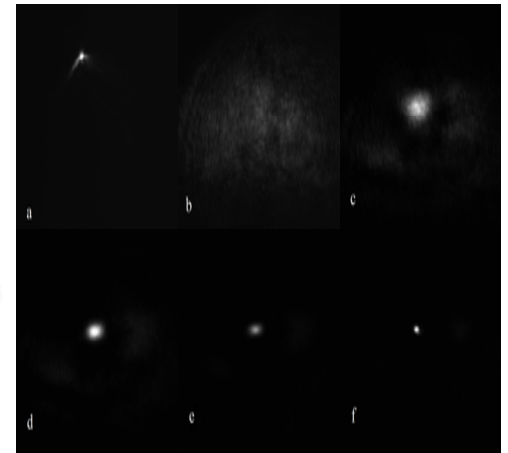
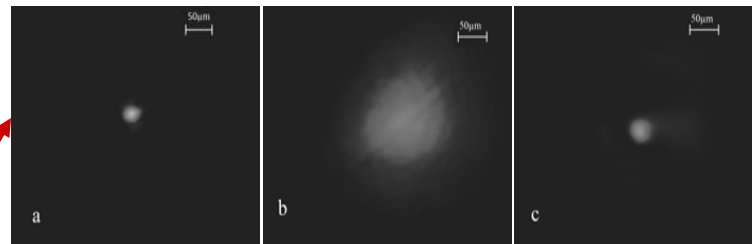
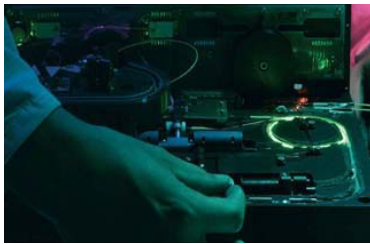


Fig.3. Writing time at 405nm vs. laser intensity

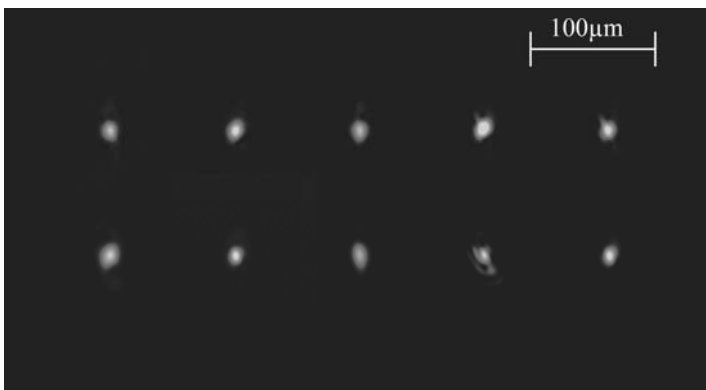
$$t_w [s] \approx \frac{107}{I [W / cm^2]} + 92$$

Collab. NILPRP with Univ. "La Sapienza" di Roma, in the frame of COST MP0702

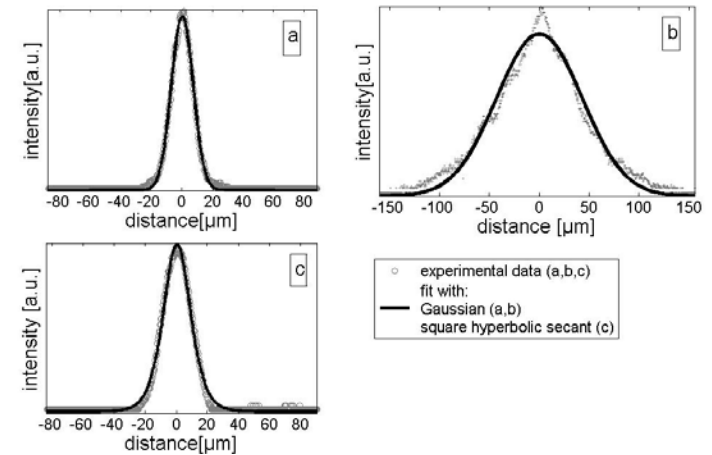
## 4.2. Fast soliton waveguide creation in lithium niobate crystals with a low power laser blue-violet diode – Fs pulse propagation in SWG arrays



**Fig. 4. Propagation of 150 fs laser pulses from ultrafast fiber lasers (1.03 μm and 1.55 μm) in SWG**



**Fig. 6. SWG array 2x5 recorded in LN crystal at  $\lambda=405\text{nm}$  ;  $1\mu\text{W}$  input power; writing time < 1h**



**Fig. 5. (a) The beam profile along its diameter on the input face of the LN crystal; (b) The beam profile on the output face of the LN crystal after free propagation; (c) The beam profile on the output face of the LN crystal when propagating through a SWG**

**Ref: 1. F. Petazzi, A. Petris, V. I. Vlad et al, *Phys. Rev. A.*, **76**, 063818 (2008);**

**2. E.Fazio, V. I. Vlad, A. Petris, Ch. 5 in « Micro-/Nano-engineering and Characterization of Ferroelectric Crystals for Photonic Applications », P. Ferraro et al. (Eds), *Springer*, 2008 (50 pag).**

**3. Petris, Vlad et al, Self-confined beams in Er-doped lithium niobate, *J. Optics*, **12**, Paper 015206 (2010); and *J. Optics*, **12**, Paper 015205 (2010)**

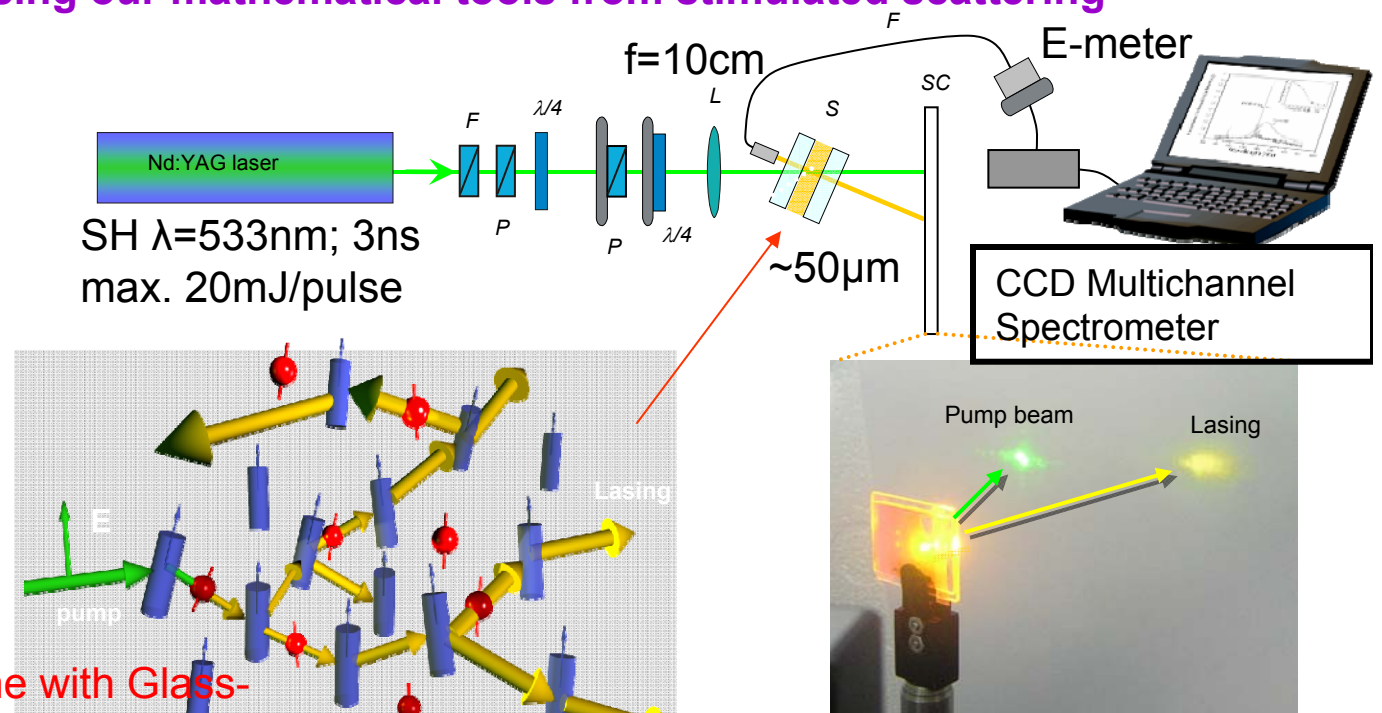
**4. S. Popescu, A. Petris, V.I. Vlad, *J.Optoelectr. Adv Mat*, **Jan. 2010**; and *Proc. SPIE*, **2010****



## 5.1. Highly efficient forward- and backward- random laser effect (without optical cavity) in dye doped nematic liquid crystals

First “random laser” in NLC: G. Strangi, S. Ferjani, [V. Barna](#), et al, Random lasing and weak localization of light in dye-doped nematic liquid crystals, *Optics Express*, **14**, 7737 (2006)

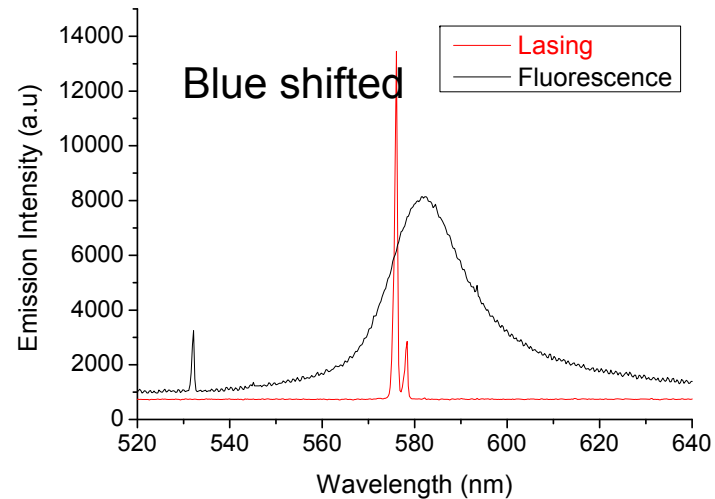
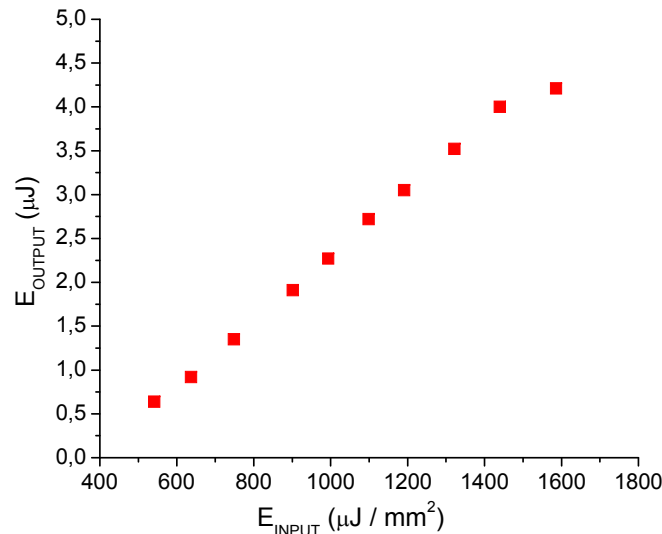
**AIM: Experimental characterization of random laser in dye-doped nematic LC and theoretical modeling of laser effect using our mathematical tools from stimulated scattering**



**Material:** Sandwich cell done with Glass-ITO plates; Align. Layers: SiO<sub>2</sub>; Nematic LC: ZLI 2659 by Merck; Dye: PM597 by Exciton (0.5 wt%)

**Collab. with Bucharest Univ.- Fac. Physics, University of Calabria - Center of Excellence CEMIF.CAL of Dept. Physics, Italy and NIMP**

## 5.2. Random laser in dye doped nematic liquid crystals Efficiency and Spectrum



**Efficiency ~ 10% (quite high for a mirrorless laser!)  
Threshold ~ 30  $\mu\text{J} / \text{mm}^2$ ;  $E_{\text{out}} \times 2$  (forw+backw)**

**Spectral properties (low pump en.)  
Sharp peaks < 0.5 nm**

**Stimulated Scattering - Damzen, Vlad, Babin, Mocofanescu, S.B.S., IOP Publ, London, 2003**

$$\frac{\partial E_P(z, r)}{\partial z} - \frac{i}{k} \left( \frac{\partial^2 E_P(z, r)}{\partial r^2} + \frac{1}{r} \cdot \frac{\partial E_P(z, r)}{\partial r} \right) = - (k \sigma_{dye}) \cdot |E_{LBackw}(z, r)|^2 \cdot E_P(z, r)$$

$$\frac{\partial E_{LBackw}(z, r)}{\partial z} + \frac{i}{k} \left( \frac{\partial^2 E_{LBackw}(z, r)}{\partial r^2} + \frac{1}{r} \cdot \frac{\partial E_{LBackw}(z, r)}{\partial r} \right) = - (k \sigma_{dye}) \cdot |E_P(z, r)|^2 \cdot E_{LBackw}(z, r)$$

$$\sigma_{dye} = g_{dye} I_0 L$$

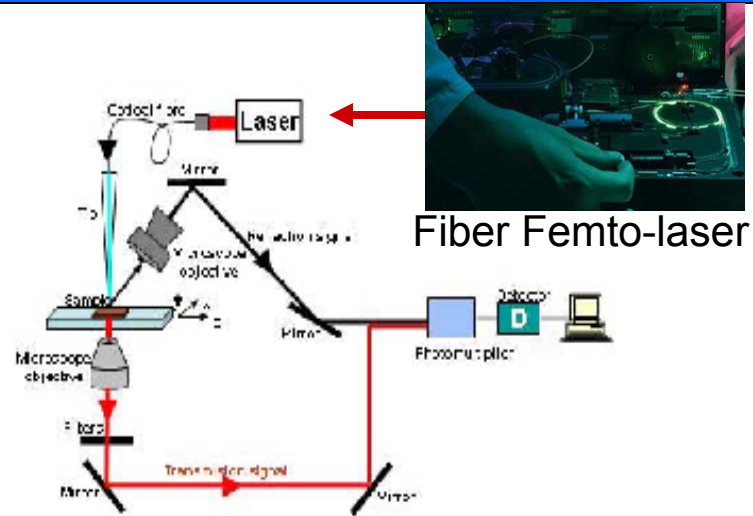
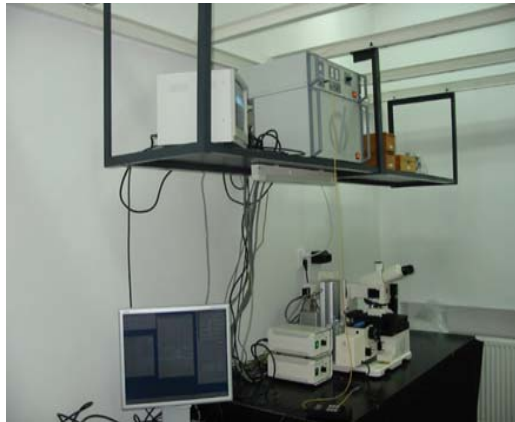
**Ref: 1. V. Barna et al, J. Nonlinear Optical Phys. & Mat., 18, 349-365(2009)**

**2. V. Barna et al, Opt. Express, 17, 13435-13440(2009)**

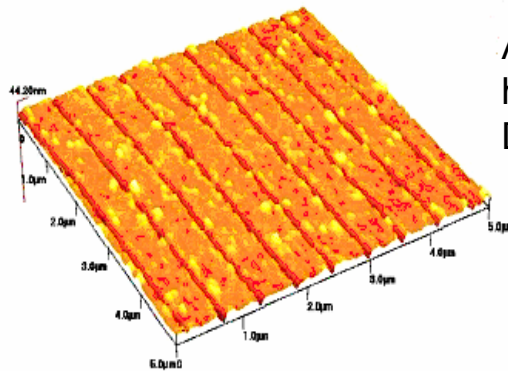
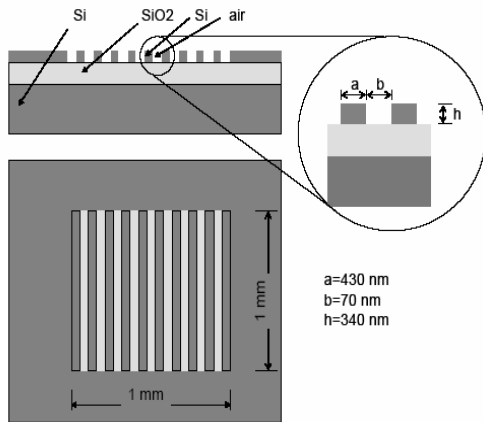
**3. V. Barna et al, Phys. Rev. Lett, 102, Article Number:167801, Apr. 24 (2009)**

**4. V. Barna et al, Opt. Express, 17, 2042-2047(2009)**

# 6.1. Imaging SOI nanostructures

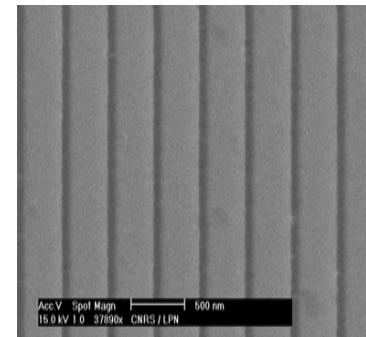


AFM Images

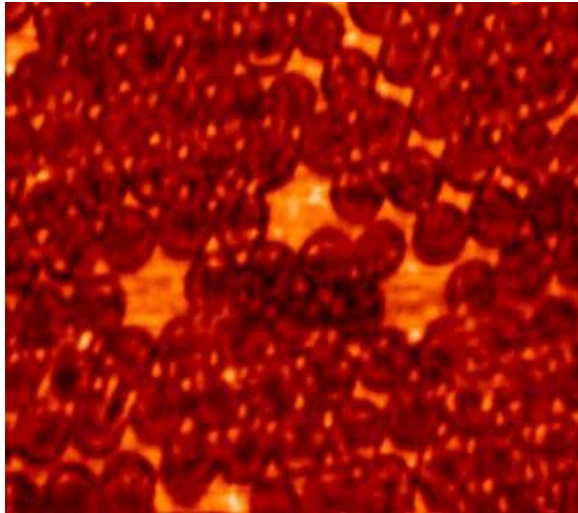


$\Lambda_2 = 530\text{ nm}$   
 $h_{\text{stripes}} = 430\text{ nm}$   
 $D_{\text{stripe}} = 70\text{ nm}$

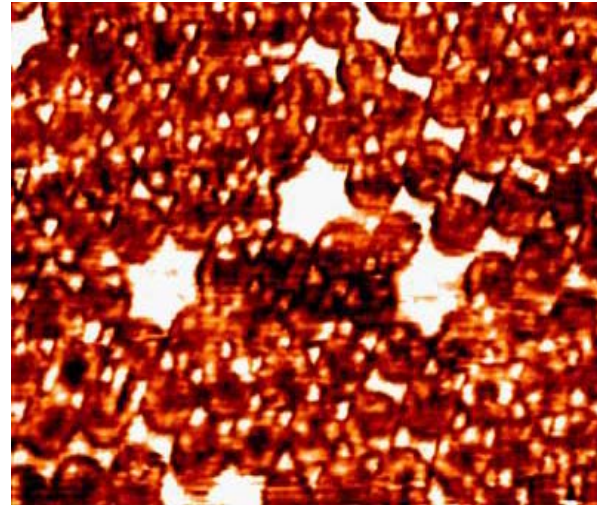
SEM Images



## 6.2. AFM si SNOM Imaging - Polystyrene nanospheres



**AFM**



**SNOM**

Polystyrene sphere (Omicron) diameter  $\sim 280$  de nm,  
Interstitial distance  $\sim 70$  de nm.



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# “NONLINEAR AND INFORMATION PHOTONICS” TEAM



Missing V. Barna, M. Udrea, M. Stoica

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to the other organizers of the 9th National Seminar  
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